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Adhesive-free bonding of polymeric components to produce closed micro- and nanochannel structures

Description

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The invention relates to a process for producing polymeric components with hollow structures present therein, e.g. in the form of closed micro- or/and nanochannels, said process using no adhesives. The

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invention further relates to the polymeric parts obtainable by the process and to their use in detection procedures.

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Polymeric components, e.g. plastic biochips, in the interior of which closed hollow structures are present have hitherto been produced by a process in which an adhesive, e.g. a UV-curable adhesive, has been used to bond a plastic outer layer onto a plastic substrate in which depressions are present. However, the use of the adhesive has led to considerable disadvantages. For example, if too much adhesive was applied, capillary interactions caused it to migrate into the channels and render these impassable, at least to some extent. On the other hand, if too little adhesive was used dead spaces were produced directly adjacent to the channels. The process was moreover highly inconvenient, since operations had to be carried out under a microscope. Finally, the presence of the adhesive also impaired the chemical or/and spectroscopic properties of the plastic component.

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DE-A-40 22 793 has disclosed that a heated welding tool can be used to weld a polymeric film onto a sheet of polymer in which recesses are present, without prior heating of the sheet of polymer or the polymeric film. The pressure of the welding tool produces a grid of point welds. The welding tool is heated to a temperature of from 250 to 300°C (column 4, lines 63-65), and therefore chemical modification of the

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polymeric materials can occur, combined with possible reduction in transparency and/or increase in base-level fluorescence. In addition, undesirable dead spaces are produced adjacent to the welds.

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The object on which the present invention is based was therefore to provide a process for producing polymeric or plastic components provided with hollow structures, said process at least to some extent avoiding the above-mentioned disadvantages of the prior art.

This object is achieved by a process for producing polymeric constituents, including the steps of:

- (a) preparing a polymeric substrate which has 15 depressions on at least one surface,
- (b) applying a polymeric covering to a surface present on the substrate and having depressions,
- (c) heating the substrate with the covering present thereupon to a temperature which is at least as 20 high as the glass transition temperature of the substrate or/and of the covering, and
- (d) cooling.

Step (a) of the novel process comprises preparing a 25 polymeric substrate with open depressions on a surface. A covering is applied to this surface with the aim of producing a polymeric component with hollow structures closed on their upward-facing sides. The polymeric substrates and polymeric coverings used for this 30 purpose are selected from the class consisting of melt-processable thermoplastics, preferably from the class consisting of acrylic polymers, polycarbonates, polystyrenes, and also copolymers and mixtures of these. It is preferably for polymeric substrates and 35 polymeric covering to be selected from among acrylic polymers, such as polyacrylate, polymethacrylate and in particular polymethyl methacrylate polymers or polycarbonates.

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The polymeric substrate has depressions on at least one surface. These depressions preferably have a width or/and depth within the range from 10 nm to 2 mm, particularly preferably from 100 nm to 1 mm and most preferably from 1 μm to 500 μm. The depressions 5 preferably comprise structures in the form of channels.

- Using the process according to the invention, a polymeric covering, for example a polymeric film, is 10 laminated onto this substrate without using adhesives. For this, substrate and covering are preferably selected from among polymeric materials of similar type, in particular from the same polymeric materials. It is moreover preferable for at least the covering and 15 in particular both the covering and the substrate to be composed of optically transparent materials, i.e. materials transparent within the visible or/and UV light regions.
- 20 To produce the substrate with a surface having depressions, a contact mask may first be produced, namely by using a laser to etch the desired microstructures into a silicon membrane under chlorine gas. (This contact mask is then laid on the plastic 25 substrate and irradiated with laser light, e.g. with a UV vacuum laser, (whereupon ablation cuts the desired channels into the plastic) The depth of cut may be set precisely via the laser and is, for example, 100 nm per irradiation. The resultant channels have a very smooth 30 surface. Removal of the mask then gives the polymeric substrate which can be used for the process according to the invention. As an alternative, the substrates provided with open microstructures may also be produced from a master mold, e.g. by injection molding.
- 35 Step (b) of the process according to the invention comprises the application of a polymeric covering onto one or more surfaces present on the substrate and having depressions. For this, the surface of the

polymeric covering, which may also be a film, for example, and the surface of the substrate are prepared in a form which is clean and as smooth as possible. The covering is then preferably positioned on the substrate 5 and the two parts combined by pressure, the pressure applied being preferably within the range from 0.1 to 1000 kg/cm², e.g. from 0.2 to 20 kg/cm².

Then, in step (c) of the process according to the 10 invention, the substrate, with the covering present thereupon, is heated to a temperature which is at least as high as the glass transition temperature of the substrate or/and of the covering. The heating preferably takes place in a controllable heating 15 cabinet, proceeding slowly from the initial temperature (e.g. room temperature) to a value just above the glass transition temperature of one of the polymers. The glass transition temperature depends on the heating rate and can readily be determined for various 20 materials by the skilled worker by simple experimentation. The duration of heating is preferably within the range from 0.5 to 3 h, particularly preferably within the range from 0.5 to 1.5 h. The heating temperature is preferably within a range 25 between the glass transition temperature and a temperature which is 5°C above the glass transition temperature. The heating temperature is particularly preferably within a range between 0.5 and 3°C above the glass transition temperature.

Once the heating temperature has been reached, the 30 substrate and the covering present thereupon are preferably held for a particular period within the range of the heating temperature. This period is 35 preferably at least 15 min, particularly preferably at least 30 min, for example from 40 to 45 min. The holding temperature is preferably within approximately ±3°C of the heating temperature.

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Step (d) of the novel process comprises the cooling. The cooling to about 40°C is preferably carried out slowly. The duration of the cooling is generally at least 1 h, particularly preferably at least 2 h and most preferably up to 3.5 h. As an alternative, the cooling may also take place within a few seconds, e.g. up to 30 sec. After the cooling, the finished polymeric part can be removed.

- 10 The novel process gives adhesive-free bonding of polymeric coverings, preferably in the form of transparent films, and structured, preferably transparent, sheets of polymeric substrate. This bonding is mechanically and chemically stable. The
15 process can be carried out at relatively low temperatures in the vicinity of the glass transition temperature, preferably just above the glass transition temperature. No reaction products are produced, and the process is therefore extremely clean and biocompatible.
20 In particular, measurements show no reduced transparency and no increased fluorescence in the resultant component. If the covering materials and substrate materials are of the same type, the component produced is composed of just a single material and has
25 optical and electrical properties superior to those of multicomponent systems. The optical quality is so high that it is even possible to detect individual molecules in channels of the components with a good signal/noise ratio.
30 The present invention further provides a polymeric component with hollow structures present therein, the component being obtainable by the process described above. The hollow structures present in this polymeric
35 component are preferably closed channels, i.e. channels closed on their upward-facing sides, with a width or/and depth of from 10 nm to 2 mm, and the component differs from polymeric parts known from the prior art in that it is essentially or even completely free from

adhesives and from thermal reaction products in its interior, in particular in the region of the hollow structures. The novel polymeric part also has full-surface bonding in the region where the surfaces of substrate and covering are in contact, so that no dead spaces are present in the region of the hollow structures. The novel polymeric part may be used for detection procedures, in particular in optical or/and electrical detection procedures.

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The invention is further described by the examples below.

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Example 1 Production of a polymethyl methacrylate component

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A PMMA film is positioned on a surface of a PMMA substrate block, which surface has micro- or/and nanochannel structures. The surfaces of both parts are clean and smooth. The two parts are placed between two flat sheets of glass, which are then clamped into a press. The pressure applied in the press is within the range from 0.2 to 20 kg/cm², e.g. 2 kg/cm². The entire system is then slowly heated, preferably within a heating time of from 0.5 to 1.5 h, in a controllable heating cabinet, to just above the glass transition temperature of the polymer. The glass transition temperature here depends on the heating rate. The ideal bonding temperature for the heating rate mentioned is

30 106 ± 0.5°C.

The system is then held for a period of from 40 to 45 min at a temperature between 104°C and the ideal bonding temperature. This is followed by slow cooling, preferably for ≤ 3.5 h. After the cooling, the finished structure can be removed from the apparatus. If desired, the cooling phase may also be considerably shortened, down to the seconds region.

Example 2 Production of a polycarbonate component

5 Using the method described in Example 1, a polycarbonate component was produced. It was found here that this material, too, was suitable for producing components with closed micro- and nanochannel structures.

10 The bonding temperature was within the range from 150 to 160°C.

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